

Application/Control No. 10/771,281	Applicant(s)/Patent under Reexamination OTTEN, JUERGEN
Examiner	Art Unit
Daniel W. Howell	3722

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· ·		ORIGINAL				INTERNATIONAL CLASSIFICATION										
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(Assistant Examiner) (Date)						Hou ∋I W.	y Ho	well	Total Claims Allowed: 17							
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(Legal Instruments Examiner) (Date)							7	16.01		3						

	Claims renumbered in the same order as presented by applicant								☐ CPA			☐ T.D.			☐ R.1.47				
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7	7			37			67			97			127			157			187
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10	10			40			70			100			130			160			190
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12	12			42			72			102			132			162			192
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